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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. |
|---|-------------|----------------------|----------------------|------------------|
| 10/502,052 | 01/07/2005 | Xavier Fanton | 255861US0PCT | 2511 |
| 2889 7590 0129/2010 OBLON, SPIVAK, MCCLELLAND MAIER & NEUSTADT, L.L.P. 1940 DUKE STREET | | | EXAMINER | |
| | | | BRAYTON, JOHN JOSEPH | |
| ALEXANDRIA, VA 22314 | | ART UNIT | PAPER NUMBER | |
| | | | 1795 | |
| | | | | |
| | | | NOTIFICATION DATE | DELIVERY MODE |
| | | | 01/20/2010 | ELECTRONIC |

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

patentdocket@oblon.com oblonpat@oblon.com jgardner@oblon.com

Application No. Applicant(s) 10/502.052 FANTON ET AL. Office Action Summary Examiner Art Unit John Brayton 1795 -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS. WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status 1) Responsive to communication(s) filed on 23 September 2009. 2a) This action is FINAL. 2b) This action is non-final. 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4) Claim(s) 1.2.5-18.20.21 and 23-26 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) _____ is/are allowed. 6) Claim(s) 1,2,5-18,20,21 and 23-26 is/are rejected. 7) Claim(s) _____ is/are objected to. 8) Claim(s) _____ are subject to restriction and/or election requirement. Application Papers 9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are; a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abevance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. Attachment(s)

1) Notice of References Cited (PTO-892)

Paper No(s)/Mail Date

Notice of Draftsperson's Patent Drawing Review (PTO-948)

information Disclosure Statement(s) (PTO/SB/08)

Interview Summary (PTO-413)
 Paper No(s)/Mail Date.

6) Other:

5) Notice of Informal Patent - polication

Application/Control Number: 10/502,052 Page 2

Art Unit: 1795

DETAILED ACTION

Status of Claims and Objections

1. Claims 1, 2, 5-18, 20, 21, 23-26 are pending.

Response to Amendment

- Applicant's amendment filed September 23, 2009 has been entered but does not place the application in condition for allowance.
- In light of the amendment the previous grounds of rejection are withdrawn and new grounds under 35 U.S.C. 103(a) are required.

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary sikil in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. The factual inquiries set forth in *Graham* v. John Deere Co., 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
 - Determining the scope and contents of the prior art.
 - 2. Ascertaining the differences between the prior art and the claims at issue.
 - Resolving the level of ordinary skill in the pertinent art.
 - Considering objective evidence present in the application indicating obviousness or nonobviousness.
- Claims 1, 2, 15, 23 and 24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Takao (US 4,107,019) in view of Lin (US 6,521,098).

Art Unit: 1795

Regarding claim 1, Applicant discloses the target is formed using an intimate blend of nickel oxide and nickel powders in order to form the target, the intimate blend would have a desired electrical resistivity (Applicant's disclosure pg. 5, In. 24-29, pg. 6, In. 30-38).

Takeo teaches a target comprising NiO_x capable of depositing film within a sputtering device (col. 8, In. 25-30). Takao discloses blending nickel oxide powder and nickel powder to form a target. This blending would result in a target with a stoichiometric composition deficient in oxygen. The target would therefore inherently have a property of electrical resistivity of 10 ohm-cm or less.

Takao does not explicitly teach a target that is comprised predominantly of nickel oxide or a magnetically enhanced sputtering device for sputtering a nickel oxide target.

Lin teaches an essentially ceramic target comprised predominantly of nickel oxide capable of depositing film within a magnetically enhanced sputtering device (col. 9, ln. 12-41).

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the target of Takao to provide an essentially ceramic target comprising predominantly nickel oxide in a magnetically enhanced sputtering device, as taught by Lin, because it would deposit a nickel oxide film with a desired crystal orientation (col. 9, In. 15-17).

Regarding claim 2, Takao teaches a sputtering target wherein the stoichiometric deficiency stems from the composition of the intimate blend formed by nickel oxide powders and nickel powders (col. 8, In. 25-30).

Art Unit: 1795

Regarding claims 23 and 24, as discussed above the resistance of the target would be an inherent property so long as the requirements of the structure of the target are met. MPEP 2112.01. Since Takao teaches the features as required by Applicant, properties of the target would be inherent. Therefore the target having an electrical resistivity of less than 1 ohm-cm or less than 0.1 ohm-cm are inherent to the target of Takao modified by Lin.

Regarding claim 15, Takao and Lin teach the use of ceramic nickel target recited in claim 1. Takao teaches a process for manufacturing a thin layer of nickel oxide using sputtering (col. 8, In. 25-30), but does not explicitly teach magnetically enhanced sputtering.

Lin teaches a process for manufacturing a thin layer of nickel oxide using magnetically enhanced sputtering (col. 9, In. 12-40).

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the method of Takao and Lin by providing a process for manufacturing a thin layer of nickel oxide using magnetically enhanced sputtering, as taught by Lin, because it would form a thin layer of nickel oxide with a desired crystal orientation (col. 9, In. 15-17).

 Claims 5, 6, 25, and 26 are rejected under 35 U.S.C. 103(a) as being unpatentable over Takao and Lin as applied to claim 1 above, in view of Arai et al (US 5,981,092 as cited in IDS).

Regarding claims 5 and 6, neither Takao nor Lin explicitly teach a minority element alloyed to nickel oxide.

Art Unit: 1795

Arai teaches a composite target (col. 3, ln. 66) comprised of predominantly of NiO (col. 4, ln. 38) with a minority element less than 50 atomic % (col. 4, ln. 43-67).

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the device of Takao and Lin, wherein nickel oxide is alloyed with a minority element less than 50 atomic %, as taught by Arai, because it would lower the resistivity and increase the quality of the film (col. 4, In. 47-50).

Regarding claims 25 and 26, neither Takao nor Lin explicitly teach the atomic percentage of the minority element is less than 30% or less than 20% calculated with respect to the nickel.

Arai teaches a sputtering target of NiO having a minority element of Boron with a volume percent of 8% compared to Nickel Oxide (col. 13, ln. 47-50). The Examiner takes the position that Arai teaches the atomic percentage of the minority element is less than 30%, or less than 20% calculated with respect to the nickel.

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the device of Takao and Lin by providing the atomic percentage of the minority element is less than 30% or less than 20% calculated with respect to the nickel, because it would lower the resistivity (col. 4, In. 45-50).

8. Claims 7-14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Takao, Lin and Arai as applied to claim 5 above in view of Campet et al. (US 5,522,976).

Regarding claim 7 and 8, neither Takao, Lin nor Arai explicitly teach a minority element whose oxide is an electroactive material with anodic coloration. Nor does it

Art Unit: 1795

teach minority elements of Co, Ir, Ru, or Rh. Takao as modified by Arai teaches a nickel oxide target alloyed with a minority element.

Campet is directed to a target for cathode sputtering. It teaches a target compound of NiO alloyed with a minority element from the metals of groups I-VIII of the Periodic table, these groups include minority elements consisting of Co, Ir, Ru, or Rh (col. 2, In. 30-36).

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the device of Takao, Lin and Arai by alloying with a minority element from the group of Co, Ir, Ru, or Rh, as taught by Campet, because it would allow these solid materials having the desired properties to be sputtered and form a high melting point target compound (col. 1, In. 24-30).

Applicant discloses minority elements whose oxide is an electroactive material with anodic coloration, such as for example Co, Ir, Ru, and Rh or from those belonging to column one of the Periodic table (for example H, Li, K and Na; Applicant's disclosure pg. 6, In. 11-18). Since Campet teaches a minority element from the group of Co, Ir, Ru, or Rh, the Examiner takes the position that an oxide of one of these minority elements is inherently an electroactive material of anodic coloration.

Regarding claims 9 and 10, neither Takao, Lin nor Arai teach minority elements whose oxide is an electroactive material with cathodic coloration. Nor do they teach minority elements of Mo, W, Re, Sn, In, Bi, or mixtures thereof.

Campet is directed to target for cathode sputtering. It teaches a target compound of NiO alloyed with a minority element from the metals of groups I-VIII of the

Art Unit: 1795

Periodic table, these groups include minority elements consisting of Mo, W, Re, Sn, In, Bi (col. 2, In. 30-36).

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the device of Takao, Lin and Arai by alloying with a minority element from the group of Mo, W, Re, Sn, In, Bi as taught by Campet, because it would allow these solid materials having the desired properties to be sputtered and form a high melting point target compound (col. 1, In. 24-30).

Applicant discloses "minority elements whose oxide is an electroactive material with cathodic coloration, chosen from the group of Mo, W, Re, Sn, In, Bi" (Applicant's disclosure pg. 6, In. 19-24). Campet teaches a minority element from the group of Mo, W, Re, Sn, In, Bi, the Examiner takes the position that an oxide of one of these minority elements is inherently an electroactive material of cathodic coloration.

Regarding claims 11 and 12, neither Takao, Lin nor Arai teach minority elements selected from the elements belonging to column one of the periodic table.

Campet is directed to a target for cathode sputtering. It teaches a target compound of NiO alloyed with a minority element from the metals of group I of the Periodic table. Group I includes minority elements of H, Li, K and Na (col. 2, In. 30-36).

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the device of Takao, Lin and Arai by alloying with a minority element from Group I of the Periodic table, as taught by Campet, because it would allow these solid materials having the desired properties to be sputtered and form a high melting point target compound (col. 1, In. 24-30).

Art Unit: 1795

Regarding claims 13 and 14, neither Takao, Lin nor Arai teach minority elements selected from the elements belonging to column one of the periodic table.

Campet is directed to a target for cathode sputtering. It teaches a target compound of Ni alloyed with a minority element that is a metal or an alkaline earth or a semiconductor. Campet also teaches a minority element selected from the group consisting of Ta, Zn, Zr, Al, Si, Sb, U, Be, Mg, Ca, V, or Y (col. 2, In. 30-36).

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the device of Takao, Lin and Arai by alloying with a minority element from the group consisting of Ta, Zn, Zr, Al, Si, Sb, U, Be, Mg, Ca, V, or Y (col. 2, In. 30-36), as taught by Campet, because it would allow these solid materials having the desired properties to be sputtered and form a high melting point target compound (col. 1, In. 24-30).

Applicant discloses a minority element selected from the group consisting of Ta, Zn, Zr, Al, Si, Sb, U, Be, Mg, Ca, V, Y is a metal or an alkaline earth or a semiconductor, wherein the hydrated or hydroxylated oxide of which is protonically conductive (Applicant's disclosure pg. 6, In. 25-30). Since Campet teaches a minority element from the group of Ta, Zn, Zr, Al, Si, Sb, U, Be, Mg, Ca, V, or Y the Examiner takes the position that the hydrated or hydroxylated oxide of one of these minority elements would be protonically conductive.

Claims 16-18 are rejected under 35 U.S.C. 103(a) as being unpatentable over
 Takao and Lin as applied to claim 15 above, in view of Hashimoto et al (US 5.831,760).

Art Unit: 1795

Regarding claim 16, Takao and Lin teach a nickel oxide layer formed by sputtering a nickel oxide target. Nickel oxide is an electrochromic material that exhibits anodic coloration. Neither Takeo nor Lin explicitly teach an oxidative colored electrochromic material comprised of nickel oxide.

Hashimoto teaches an oxidative colored electrochromic layer comprised of nickel oxide (col. 4, ln. 37-49).

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the method of Takao and Lin by producing an electrochromic material having an anodic coloration as a thin layer based on nickel oxide, because it would provide a layer with good optical properties and repeated durability (col. 4, In. 42-45 of Hashimoto).

Regarding claim 17, Takao and Lin teach a nickel oxide layer formed by sputtering a nickel oxide target. Neither Takao nor Lin explicitly teach an electrochemical device comprising a substrate provided with a stack of functional layers.

Hashimoto teaches an electrochemical device comprising a substrate provided with a stack of functional layers (Figures 1-6, Abstract of Hashimoto), including a layer based on nickel oxide (col. In. 37-49).

The Examiner takes the position that the recitation "capable of" performs a function and is not a positive limitation but only requires the ability to so perform.

Therefore the language "capable of reversibly and simultaneously inserting ions of the H+, Li+, or OH- type and electrons" is not given patentable weight.

Art Unit: 1795

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the device of Takao and Lin to provide an electrochemical device comprising a substrate provided with a stack of functional layers including a layer based on nickel oxide, as taught by Hashimoto, because it would provide a layer with good optical properties and repeated durability (col. 4, In. 42-45 of Hashimoto).

Regarding claim 18, Takao and Lin teach a nickel oxide layer formed by sputtering a nickel oxide target. Takao and Lin do not explicitly teach an electrochemical device comprising a substrate provided with a stack of functional layers.

Hashimoto teaches an electrochemical device comprising a substrate provided with a stack of functional layers (Figures 1-6, Abstract of Hashimoto), including a layer based on nickel oxide, said layer being alloyed with a minority element consisting of a material whose oxide is an electroactive material with anodic coloration (col. In. 37-49).

The Examiner takes the position that the recitation "capable of" performs a function and is not a positive limitation but only requires the ability to so perform.

Therefore the language "capable of reversibly and simultaneously inserting ions of the H+, Li+, or OH- type and electrons" is not given patentable weight.

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the device of Takao and Lin by providing an electrochemical device comprising a substrate provided with a stack of functional layers, including a layer based on nickel oxide, said layer being alloyed with a minority element consisting of a material whose oxide is an electroactive material with anodic coloration, as taught

Art Unit: 1795

by Hashimoto, because it would provide a layer with good optical properties and repeated durability (col. 4, ln. 42-45 of Hashimoto)

The properties of the layer being an electrochemically active layer with a minority element consisting of a material whose oxide is an electroactive material with anodic coloration are inherent to a nickel oxide layer with a minority element consisting of Co, Ir Ru or Rh, as disclosed by Applicant on page 6, In. 11-18.

 Claim 20 is rejected under 35 U.S.C. 103(a) as being unpatentable over Takao, and Lin as applied to claim 1 above, in view of IBM Technical Disclosure: Thermally Stable Thin Film Capacitor, February 1967.

Regarding claim 20, Takao, and Lin teach a nickel oxide layer formed by sputtering a nickel oxide target. Neither Takao, nor Lin explicitly teach an electrochemical device comprising a substrate provided with a stack of functional layers.

The IBM Tech. Disclosure teaches an electrochemical device comprising at least one carrier substrate provided with a stack of functional layers, including at least one electrochemically active layer, capable of reversibly and simultaneously inserting ions, of the H.sup.+, Li.sup.+ or OH.sup.- type, and electrons, wherein said electrochemically active layer is based on nickel oxide, said layer being alloyed with a minority element selected from the elements belonging to the column one of the Periodic Table, said layer being obtained from a sputtering target.

The Examiner takes the position that the recitation "capable of" performs a function and is not a positive limitation but only requires the ability to so perform.

Art Unit: 1795

Therefore the language "capable of reversibly and simultaneously inserting ions of the H+, Li+, or OH- type and electrons" is not given patentable weight.

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the device of Takao and Lin by providing an electrochemical device with a stack of functional layers including at least on electrochemically active layer based on nickel oxide alloyed with a minority element selected from column one of the Periodic Table, because it would produce a device with a high capacitance per unit area and maintain stability during and after exposure to high temperature environments (IBM Tech. Disclosure pg. 1).

 Claim 21 is rejected under 35 U.S.C. 103(a) as being unpatentable over Takao and Lin as applied to claim 1 above in view of Van Der Sluis (US 5,905,590).

Regarding claim 21, Takao, and Lin teach a nickel oxide layer formed by sputtering a nickel oxide target. Neither Takao nor Lin explicitly teach an electrochemical device comprising a substrate provided with a stack of functional layers.

Van Der Sluis teaches an electrochemical device comprising at least one carrier substrate (figure 1, 3) provided with a stack of functional layers (Figure 1; reference numbers 5, 7, 9, 11, 13) including at least one electrochemically active layer (col. 4, ln 4-30), capable of reversibly and simultaneously inserting ions, of the H.sup.+, Li.sup.+ or OH.sup.- type, and electrons, wherein said electrochemically active layer is a metal or an alkaline earth or a semiconductor, the hydrated or hydroxylated oxide of which is protonically conducted by sputtering (col. 4, ln. 25-26).

Art Unit: 1795

Since Van Der Sluis teaches a layer of a metal or an alkaline earth or a semiconductor, the properties of this layer wherein the hydrated or hydroxlyated oxide of the layer would be capable of protonically conducting are inherent. Therefore the hydrated or hydroxlyated oxide of the layer taught by Van Der Sluis would be capable of protonically conducting.

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to modify the device of Takao and Lin with an electrochemical device comprising at least one carrier substrate provided with a stack of functional layers, including at least one electrochemically active layer, capable of reversibly and simultaneously inserting ions, of the H.sup.+, Li.sup.+ or OH.sup.- type, and electrons, wherein said electrochemically active layer is a metal or an alkaline earth or a semiconductor, the hydrated or hydroxylated oxide of which is protonically conducted, as taught by Van Der Sluis, because it would allow use of solid state electrolytes therefore eliminating sealing problems and making the device easier to handle (col. 4, In. 4-6).

Response to Arguments

 Applicant's arguments filed September 23, 2009 have been fully considered but they are not persuasive.

Applicant argues that neither Takao nor lida teach a magnetically enhanced sputtering device. The examiner cites Lin teaching a magnetically enhanced sputtering device.

Applicant argues that Takao's target of a compacted powder does not appear to be a ceramic target required by claim 1.

In reply, the Examiner above cites Lin which teaches a ceramic nickel oxide target.

Applicant argues that there is no evidence in Takao's powder that the nickel oxide is oxygen deficient. The Examiner takes the position that oxygen and nickel are discrete units. Therefore to have a powder that is stoichiometrically deficient in oxygen would require less oxygen, it follows that having less oxygen requires more nickel. Since Takao's powder contains a nickel oxide power and a nickel power the target would be stoichiometrically deficient in oxygen because there is nickel added to the target. This embodiment of the invention has been recited in claim 2.

Conclusion

13. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, THIS ACTION IS MADE FINAL. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

Art Unit: 1795

the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to John Brayton whose telephone number is (571)270-3084. The examiner can normally be reached on 7:30 a.m. - 5:00 p.m. EST.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nam Nguyen can be reached on (571) 272-1342. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Nam X Nguyen/ Supervisory Patent Examiner, Art Unit 1753

/J. B./ Examiner, Art Unit 1795 January 12, 2009